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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/021,437	12/19/2001	Yasuhiro Matsuoka	KOJIM 200-D-1	3284
23599	7590	10/27/2004	EXAMINER	
MILLEN, WHITE, ZELANO & BRANIGAN, P.C. 2200 CLARENDON BLVD. SUITE 1400 ARLINGTON, VA 22201			LUK, EMMANUEL S	
		ART UNIT		PAPER NUMBER
				1722

DATE MAILED: 10/27/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

<b>Office Action Summary</b>	<b>Application No.</b>	<b>Applicant(s)</b>
	10/021,437	MATSUOKA ET AL.
	<b>Examiner</b>	<b>Art Unit</b>
	Emmanuel S. Luk	1722

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --  
**Period for Reply**

**A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.**

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) Responsive to communication(s) filed on 12 August 2004.
- 2a) This action is **FINAL**.                    2b) This action is non-final.
- 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) Claim(s) 6,8-12 and 14-29 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) Claim(s) \_\_\_\_\_ is/are allowed.
- 6) Claim(s) 6,8-12 and 14-29 is/are rejected.
- 7) Claim(s) \_\_\_\_\_ is/are objected to.
- 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) The specification is objected to by the Examiner.
- 10) The drawing(s) filed on \_\_\_\_\_ is/are: a) accepted or b) objected to by the Examiner.  
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
  - a) All    b) Some \* c) None of:
    1. Certified copies of the priority documents have been received.
    2. Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
    3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- |   |   |
|---|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)             | 4) <input type="checkbox"/> Interview Summary (PTO-413)                     |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)    | Paper No(s)/Mail Date. _____ .  |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| Paper No(s)/Mail Date _____ .   | 6) <input type="checkbox"/> Other: _____ .                                  |

## DETAILED ACTION

### ***Claim Rejections - 35 USC § 103***

1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

2. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

3. Claims 6, 9-12, 14 and 21-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Boneberger et al (5894002) in view of Schueller (6143412) and Gibson (5093067).

Boneberger teaches the claimed apparatus having a mold (1,2) having a cavity (12) corresponding to the outer contour of an article to be duplicated, the mold being transparent (Col. 6, lines 19-24), means for casting or filling (6) the mold cavity, means for irradiating light (7) from outside the mold.

Boneberger fails to teach a mother mold and the mother mold is made from a photo-curable liquid silicone rubber composition.

Schueller teaches a mold structure (20) comprising of a cured polyorganosiloxane, specifically polydimethyl siloxane (Col. 12, lines 10). The compositional formula of the claimed apparatus is a commonly available cured polysiloxane. Thus, it would have been obvious to one of ordinary skill in the art to have a mold comprised of this material as seen in Schueller.

The mold halves taught by Boneberger forms the cavity. The mother mold has the same function as a mold if it is not already the same thing with an alternate name. Gibson teaches materials can be made from liquid silicone rubber, commercially available by Dow Corning that is injected into a mold and cured to form a product. The product can be used including as a mold for forming other products.

It would have been obvious to one of ordinary skill in the art to modify Boneberger with mother molds that have the same function in forming a cavity for shaping the outer contour of the desired product and the mold made from liquid silicone rubber as taught by Gibson because it allows for the mold to be shaped to the desired shape and thus creating the desired product shape.

In regards to claims 9 and 21, the wavelength range of 200 to 500 nm is in the visible light spectrum and thus the light source taught by Boneberger would cover the wavelength range claimed.

In regards to claims 10, 11, 22 and 23, these features are properties of the silicone rubber composition and thus do not further limit the parent claim if the properties are already inherent features of the material.

In regards to claims 12 and 24, the material to be filled in the mold cavity is an intended use of the apparatus and has little patentable weight since there is no further structural limitation to the parent claim.

4. Claim 8 and 25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Boneberger (5894002) in view Schueller and Gibson as applied to claims 6, 9-12, 14 and 21-24 above, and further in view of Hayashi et al (4995799).

Boneberger fails to teach agitating and defoaming under reduced pressure.

Hayashi teaches an optical manufacturing apparatus having a gas pressure control mean and defoaming means to defoam the photopolymer (Col. 15, lines 50-57). Thus, the polymer is defoamed under reduced pressure, thereby it would have been obvious to one of ordinary skill in the art to modify Boneberger with gas pressure control mean and defoaming means as taught by Hayashi because it allows for defoaming of the polymer prior to curing.

5. Claims 17 -19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Boneberger in view of Schueller and Gibson as applied to claims 6 and 9-12 above, and further in view of Tensor (5885514).

Boneberger in view of Schueller and Gibson fails to teach the mother mold separable to two or more sections and the means for irradiating is one or more UV fluorescent lamps.

Tensor teaches a transparent mold comprising of two sections (30,40) that is used for forming and the use of infrared lamps (42), the mold having runners (52) for filling the cavity via injection molding (Col. 49-55).

It would have been obvious to one of ordinary skill in the art to modify Boneberger in view of Gibson with mold sections, runner and UV lamps as taught by Tensor because it allow for an improved process for molding parts.

6. Claims 15 and 26-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Boneberger et al (5894002) in view of Schueller (6143412), Gibson (5093067) and Nakamura (5112512).

Boneberger teaches the claimed apparatus having a mold (1,2) having a cavity (12) corresponding to the outer contour of an article to be duplicated, the mold being transparent (Col. 6, lines 19-24), means for casting or filling (6) the mold cavity, means for irradiating light (7) from outside the mold.

Boneberger fails to teach a mother mold and the mother mold is made from a photo-curable liquid silicone rubber composition and a platinum catalyst.

Schueller teaches a mold structure (20) comprising of a cured polyorganosiloxane, specifically polydimethyl siloxane (Col. 12, lines 10). The compositional formula of the claimed apparatus is a commonly available cured polysiloxane. Thus, it would have been obvious to one of ordinary skill in the art to have a mold comprised of this material as seen in Schueller.

The mold halves taught by Boneberger forms the cavity. The mother mold has the same function as a mold if it is not already the same thing with an alternate name.

Gibson teaches materials can be made from liquid silicone rubber, commercially available by Dow Corning that is injected into a mold and cured to form a product. The product can be used including as a mold for forming other products.

Nakamura teaches the creation of crosslinked organopolysiloxane structures that are created with the aid of a platinum catalyst (Col. 6, line 56).

It would have been obvious to one of ordinary skill in the art to modify Boneberger with mother molds that have the same function in forming a cavity for shaping the outer contour of the desired product and the mold made from liquid silicone rubber as taught by Gibson because it allows for the mold to be shaped to the desired shape and thus creating the desired product shape.

In regards to claim 26, the wavelength range of 200 to 500 nm is in the visible light spectrum and thus the light source taught by Boneberger would cover the wavelength range claimed.

In regards to claims 27 and 28, these are features are properties of the silicone rubber composition and thus do not further limit the parent claim if the properties are already inherent features of the material.

In regards to claim 29, the material to be filled in the mold cavity is an intended use of the apparatus and has little patentable weight since there is no further structural limitation to the parent claim.

7. Claim 25 is rejected under 35 U.S.C. 103(a) as being unpatentable over Boneberger (5894002) in view Schueller (6143412), Gibson (5093067) and Nakamura

(5112512) as applied to claims 15 and 26-29 above, and further in view of Hayashi et al (4995799).

Boneberger in view of Schueller, Gibson and Nakamura fail to teach agitating and defoaming under reduced pressure.

Hayashi teaches an optical manufacturing apparatus having a gas pressure control mean and defoaming means to defoam the photopolymer (Col. 15, lines 50-57). Thus, the polymer is defoamed under reduced pressure, thereby it would have been obvious to one of ordinary skill in the art to modify Boneberger in view of Schueller, Gibson and Nakamura with gas pressure control mean and defoaming means as taught by Hayashi because it allows for defoaming of the polymer prior to curing.

#### ***Response to Arguments***

8. Applicant's arguments with respect to claims 6, 8-12 and 14-29 have been considered but are moot in view of the new ground(s) of rejection. The new prior art references, Schueller, teaches the material forming the mold structure.

#### ***Conclusion***

9. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Everhart (6221579).

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Emmanuel S. Luk whose telephone number is (571)

272-1134. The examiner can normally be reached on Monday-Thursday 7 to 4 and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ben Utech can be reached on (571) 272-1137. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

EL

*[Signature]*  
BENJAMIN L. UTECH  
SUPERVISORY PATENT EXAMINER  
TECHNOLOGY CENTER 1700